

JPW



In re Application of:

SHOJI NISHIDA, ET AL.

Application No.: 10/676,094

Filed: October 2, 2003

For: LIQUID PHASE GROWTH METHOD FOR
SILICON CRYSTAL,
MANUFACTURING METHOD FOR SOLAR
CELL AND LIQUID PHASE GROWTH
APPARATUS FOR SILICON CRYSTAL

Docket No.

03560.003363.

Examiner: F. Hiteshew

Group Art Unit: 1722

Date: July 1, 2005

Mail Stop Amendment
THE COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Transmitted herewith is an Amendment in the above-identified application.

☒ No additional fee is required.

The fee has been calculated as shown below

CLAIMS AS AMENDED						
	(2) CLAIMS REMAINING AFTER AMENDMENT		(4) HIGHEST NO. PREVIOUSLY PAID FOR	(5) PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	* 33	MINUS	** 33	= 0	x \$25 \$50	\$0.00
INDEP. CLAIMS	* 6	MINUS	*** 6	= 0	x \$100 \$200	\$0.00
Fee for Multiple Dependent claims \$180°/\$360						\$0.00
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT---						\$0.00


* If the entry in Column 2 is less than the entry in Column 4, write "0" in Column 5.

** If the "Highest Number Previously Paid For" IN THIS SPACE is less than 20, write "20" in this space.

*** If the "Highest Number Previously Paid For" IN THIS SPACE is less than 3, write "3" in this space.

- ☐ Verified Statement claiming small entity status is enclosed, if not filed previously.
- ☐ A check in the amount of \$_____ is enclosed.
- ☐ Charge \$_____ to Deposit Account No. 06-1205. A duplicate copy of this sheet is enclosed.
- ☒ Any prior general authorization to charge an issue fee under 37 C.F.R. 1.18 to Deposit Account No. 06-1205 is hereby revoked. The Commissioner is hereby authorized to charge any additional fees under 37 C.F.R. 1.16 and 1.17 which may be required during the entire pendency of this application, or to credit any overpayment, to Deposit Account No. 06-1205. A duplicate copy of this paper is enclosed.
- ☐ A check in the amount of \$_____ to cover the fee for a _____ month extension is enclosed.
- ☐ A check in the amount of \$_____ to cover the Information Disclosure Statement fee is enclosed.
- ☒ Applicants' undersigned attorney may be reached in our Costa Mesa, California office by telephone at (714) 540-8700. All correspondence should continue to be directed to our address given below.

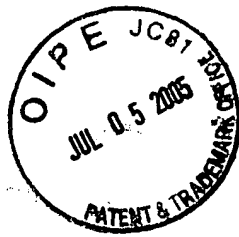
Respectfully submitted,



Damond E. Vadnais
Attorney for Applicants
Registration No.: 52,310

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3800
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03560.003363.



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
	:	Examiner: F. Hiteshew
SHOJI NISHIDA, ET AL.)	
	:	Group Art Unit: 1722
Application No.: 10/676,094)	
	:	
Filed: October 2, 2003)	
	:	
For: LIQUID PHASE GROWTH)	
METHOD FOR SILICON	:	
CRYSTAL,)	
MANUFACTURING METHOD	:	
FOR SOLAR CELL AND)	
LIQUID PHASE GROWTH	:	
APPARATUS FOR SILICON)	
CRYSTAL	:	July 1, 2005

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office Action dated April 4, 2005, please amend the
above-identified application as follows.